

HCS21MS

Radiation Hardened Dual 4-Input AND Gate

September 1995

Features

- 3 Micron Radiation Hardened SOS CMOS
- · Total Dose 200K RAD (Si)
- SEP Effective LET No Upsets: >100 MEV-cm²/mg
- Single Event Upset (SEU) Immunity < 2 x 10⁻⁹ Errors/Bit-Day (Tvp)
- Dose Rate Survivability: >1 x 10¹² RAD (Si)/s
- Dose Rate Upset >10¹⁰ RAD (Si)/s 20ns Pulse
- · Latch-Up Free Under Any Conditions
- Military Temperature Range: -55°C to +125°C
- · Significant Power Reduction Compared to LSTTL ICs
- DC Operating Voltage Range: 4.5V to 5.5V
- · Input Logic Levels
 - VIL = 30% of VCC Max
 - VIH = 70% of VCC Min
- Input Current Levels Ii ≤ 5μA at VOL, VOH

Description

The Harris HCS21MS is a Radiation Hardened Dual Input AND Gate. A high on all inputs forces the output to a High state.

The HCS21MS utilizes advanced CMOS/SOS technology to achieve high-speed operation. This device is a member of radiation hardened, high-speed, CMOS/SOS Logic Family.

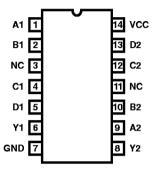
The HCS21MS is supplied in a 14 lead Ceramic flatpack (K suffix) or a SBDIP Package (D suffix).

Ordering Information

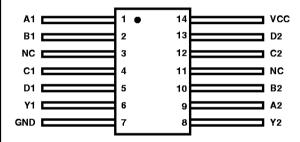
PART NUMBER	TEMPERATURE RANGE	SCREENING LEVEL	PACKAGE
HCS21DMSR	-55°C to +125°C	Harris Class S Equivalent	14 Lead SBDIP
HCS21KMSR	-55°C to +125°C	Harris Class S Equivalent	14 Lead Ceramic Flatpack
HCS21D/ Sample	+25°C	Sample	14 Lead SBDIP
HCS21K/ Sample	+25°C	Sample	14 Lead Ceramic Flatpack
HCS21HMSR	+25°C	Die	Die

Pinouts

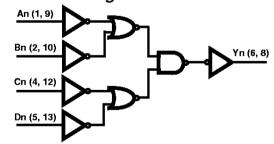
14 LEAD CERAMIC DUAL-IN-LINE METAL SEAL PACKAGE (SBDIP) MIL-STD-1835 CDIP2-T14, LEAD FINISH C TOP VIEW



14 LEAD CERAMIC METAL SEAL FLATPACK PACKAGE (FLATPACK) MIL-STD-1835 CDFP3-F14, LEAD FINISH C
TOP VIEW



Functional Diagram



TRUTH TABLE

	INP	OUTPUTS		
An	Bn	Cn	Dn	Yn
L	X	X	Х	L
Х	L	X	Х	L
Х	Х	L	Х	L
Х	X	X	L	Ĺ
Н	Н	НХ	Н	Н

NOTE: L = Logic Level Low, H = Logic level High, X = Don't Care

Absolute Maximum Ratings

J
Supply Voltage
Input Voltage Range, All Inputs0.5V to VCC +0.5V
DC Input Current, Any One Input±10mA
DC Drain Current, Any One Output±25mA
(All Voltage Reference to the VSS Terminal)
Storage Temperature Range (TSTG)65°C to +150°C
Lead Temperature (Soldering 10sec) +265°C
Junction Temperature (TJ) +175°C
ESD Classification

Reliability Information

Thermal Resistance SBDIP Package	θ _{JA} 74°C/W	θ _{JC} 24°C/W
Ceramic Flatpack Package	116°C/W	30°C/W
Maximum Package Power Dissipation at +125	5°C Ambien	t
SBDIP Package		0.68W
Ceramic Flatpack Package		0.43W
If device power exceeds package dissipation of	capability, p	rovide heat
sinking or derate linearly at the following rate:		
SBDIP Package	1	3.5mW/°C
Ceramic Flatpack Package		8.6mW/°C

...... 0.0V to 30% of VCC 70% of VCC of VCC

CAUTION: As with all semiconductors, stress listed under "Absolute Maximum Ratings" may be applied to devices (one at a time) without resulting in permanent damage. This is a stress rating only. Exposure to absolute maximum rating conditions for extended periods may affect device reliability. The conditions listed under "Electrical Performance Characteristics" are the only conditions recommended for satisfactory device operation.

Operating Conditions

Supply Voltage	5.5V Input Low Voltage (VIL)
Input Rise and Fall Times at 4.5V VCC (TR, TF) 100ns	Max Input High Voltage (VIH)
Operating Temperature Range (T _A)55°C to +12	25°C

TABLE 1. DC ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTE 1)	GROUP A SUB-		LIM	IITS	
PARAMETER	SYMBOL	CONDITIONS	GROUPS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	1	+25°C	-	10	μΑ
		VIIV = VOO OI GIVD	2, 3	+125°C, -55°C	•	200	μΑ
Output Current (Sink)	IOL	VCC = 4.5V, VIH = 4.5V, VOUT = 0.4V, VIL = 0V	1	+25°C	4.8	-	mA
(SIIIK)		VOOT = 0.4V, VIL = 0V	2, 3	+125°C, -55°C	4.0	-	mA
Output Current (Source)	ЮН	VCC = 4.5V, VIH = 4.5V, VOUT = VCC -0.4V.	1	+25°C	-4.8	-	mA
(Source)		VIL = 0V	2, 3	+125°C, -55°C	-4.0	-	mA
Output Voltage Low	VOL	VCC = 4.5V, VIH = 3.15V, IOL = 50μA, VIL = 1.35V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	٧
		VCC = 5.5V, VIH = 3.85V, IOL = 50μA, VIL = 1.65V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	٧
Output Voltage High	VOH	VCC = 4.5V, VIH = 3.15V, IOH = -50μA, VIL = 1.35V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	٧
		VCC = 5.5V, VIH = 3.85V, IOH = -50μA, VIL = 1.65V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	V
Input Leakage Current	IIN	VCC = 5.5V, VIN = VCC or GND	1	+25°C	-	±0.5	μΑ
Current		GND	2, 3	+125°C, -55°C	-	±5.0	μΑ
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 0.70(VCC), (Note 2) VIL = 0.30(VCC)	7, 8A, 8B	+25°C, +125°C, -55°C	-	-	-

NOTES:

- 1. All voltages reference to device GND.
- 2. For functional tests, $VO \ge 4.0V$ is recognized as a logic "1", and $VO \le 0.5V$ is recognized as a logic "0".

TABLE 2. AC ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTEC 1 O)	GROUP NOTES 1, 2) A SUB-		LIM	LIMITS	
PARAMETER	SYMBOL	(NOTES 1, 2) CONDITIONS	GROUPS	TEMPERATURE	MIN	МАХ	UNITS
Input to Y	TPHL	VCC = 4.5V	9	+25°C	2	18	ns
	TPLH	VCC = 4.5V	10, 11	+125°C, -55°C	2	20	ns
Input to YN	TPHL	VCC = 4.5V	9	+25°C	2	20	ns
	TPLH	VCC = 4.5V	10, 11	+125°C, -55°C	2	22	ns

NOTES:

- 1. All voltages referenced to device GND.
- 2. AC measurements assume RL = 500Ω , CL = 50pF, Input TR = TF = 3ns, VIL = GND, VIH = VCC.

TABLE 3. ELECTRICAL PERFORMANCE CHARACTERISTICS

				L		IITS	
PARAMETER	SYMBOL	CONDITIONS	NOTES	TEMPERATURE	MIN	MAX	UNITS
Capacitance Power	CPD	VCC = 5.0V, f = 1MHz	1	+25°C	-	39	pF
Dissipation			1	+125°C, -55°C	-	44	pF
Input Capacitance	CIN	VCC = 5.0V, f = 1MHz	1	+25°C	-	10	pF
			1	+125°C, -55°C	-	10	pF
Output Transition	TTHL	VCC = 4.5V	1	+25°C	-	15	ns
Time	TTLH		1	+125°C, -55°C	-	22	ns

NOTE:

TABLE 4. DC POST RADIATION ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTES 1, 2)		200K RA	DLIMITS	
PARAMETER	SYMBOL	CONDITIONS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	+25°C	-	0.2	mA
Output Current (Sink)	IOL	VCC = 4.5V, VIN = VCC or GND, VOUT = 0.4V	+25°C	4.0	-	mA
Output Current (Source)	IOH	VCC = 4.5V, VIN = VCC or GND, VOUT = VCC -0.4V	+25°C	-4.0	-	mA
Output Voltage Low	VOL	VCC = 4.5V and 5.5V, VIH = 0.70(VCC), VIL = 0.30(VCC), IOL = 50µA	+25°C	-	0.1	٧
Output Voltage High	VOH	VCC = 4.5V and 5.5V, VIH = 0.70(VCC), VIL = 0.30(VCC), IOH = -50μA	+25°C	VCC -0.1	-	٧
Input Leakage Current	IIN	VCC = 5.5V, VIN = VCC or GND	+25°C	-	±5	μΑ
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 0.70(VCC), VIL = 0.30(VCC), (Note 3)	+25°C	-	-	-
Input to Y	TPHL	VCC = 4.5V	+25°C	2	20	ns
	TPLH	VCC = 4.5V	+25°C	2	22	ns

NOTES:

- 1. All voltages referenced to device GND.
- 2. AC measurements assume RL = 500Ω , CL = 50pF, Input TR = TF = 3ns, VIL = GND, VIH = VCC.
- 3. For functional tests, VO ≥ 4.0V is recognized as a logic "1", and VO ≤ 0.5V is recognized as a logic "0".

^{1.} The parameters listed in Table 3 are controlled via design or process parameters. Min and Max Limits are guaranteed but not directly tested. These parameters are characterized upon initial design release and upon design changes which affect these characteristics..

TABLE 5. BURN-IN AND OPERATING LIFE TEST, DELTA PARAMETERS (+25°C)

PARAMETER	GROUP B SUBGROUP	DELTA LIMIT
ICC	5	ЗµА
IOL/IOH	5	-15% of 0 Hour

TABLE 6. APPLICABLE SUBGROUPS

CONFORMANCE GROUPS		METHOD	GROUP A SUBGROUPS	READ AND RECORD
Initial Test (Preburn-In)	Initial Test (Preburn-In)		1, 7, 9	ICC, IOL/H
Interim Test 1 (Postburn-	ln)	100%/5004	1, 7, 9	ICC, IOL/H
Interim Test II (Postburn-	·ln)	100%/5004	1, 7, 9	ICC, IOL/H
PDA		100%/5004	1, 7, 9, Deltas	
Interim Test III (Postburn	Interim Test III (Postburn-In)		1, 7, 9	ICC, IOL/H
PDA		100%/5004	1, 7, 9, Deltas	
Final Test		100%/5004	2, 3, 8A, 8B, 10, 11	
Group A (Note 1)		Sample/5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11	
Group B Subgroup B-5		Sample/5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11, Deltas	Subgroups 1, 2, 3, 9, 10, 11
Subgroup B-6		Sample/5005	1, 7, 9	
Group D		Sample/5005	1, 7, 9	

NOTE: 1. Alternate Group A testing in accordance with Method 5005 of MIL-STD-883 may be exercised.

TABLE 7. TOTAL DOSE IRRADIATION

CONFORMANCE		TEST		READ ANI	DRECORD
GROUPS	METHOD	PRE RAD	POST RAD	PRE RAD	POST RAD
Group E Subgroup 2	5005	1, 7, 9	Table 4	1, 9	Table 4 (Note 1)

NOTE:

1. Except FN test which will be performed 100% Go/No-Go.

TABLE 8. STATIC AND DYNAMIC BURN-IN TEST CONNECTIONS

				OSCILLATOR			
OPEN	GROUND	1/2 VCC = 3V ± 0.5V	VCC = 6V \pm 0.5V	50kHz	25kHz		
STATIC BURN-IN I TEST CONDITIONS (Note 1)							
3, 6, 8, 11	1, 2, 4, 5, 7, 9, 10, 12, 13	-	14	-	-		
STATIC BURN-IN II TEST CONNECTIONS (Note 1)							
3, 6, 8, 11	7	-	1, 2, 4, 5, 9, 10, 12, 13, 14	-	-		
DYNAMIC BURN-IN I TEST CONNECTIONS (Note 2)							
-	7	3, 6, 8, 12	14	1, 2, 4, 5, 9, 10, 12, 13	-		

NOTES:

- 1. Each pin except VCC and GND will have a resistor of 10K Ω \pm 5% for static burn-in.
- 2. Each pin except VCC and GND will have a resistor of 1K $\!\Omega\pm5\%$ for dynamic burn-in.

TABLE 9. IRRADIATION TEST CONNECTIONS

OPEN	GROUND	VCC = 5V ± 0.5V
3, 6, 8, 11	7	1, 2, 4, 5, 9, 10, 12, 13, 14

NOTE: Each pin except VCC and GND will have a resistor of $47 \text{K}\Omega \pm 5\%$ for irradiation testing. Group E, Subgroup 2, sample size is 4 dice/wafer 0 failures.

HCS21MS

Harris Space Level Product Flow - 'MS'

Wafer Lot Acceptance (All Lots) Method 5007 (Includes SEM)

GAMMA Radiation Verification (Each Wafer) Method 1019, 4 Samples/Wafer, 0 Rejects

100% Nondestructive Bond Pull, Method 2023

Sample - Wire Bond Pull Monitor, Method 2011

Sample - Die Shear Monitor, Method 2019 or 2027

100% Internal Visual Inspection, Method 2010, Condition A

100% Temperature Cycle, Method 1010, Condition C, 10 Cycles

100% Constant Acceleration, Method 2001, Condition per Method 5004

100% PIND, Method 2020, Condition A

100% External Visual

100% Serialization

100% Initial Electrical Test (T0)

100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C min., Method 1015

100% Interim Electrical Test 1 (T1)

100% Delta Calculation (T0-T1)

100% Static Burn-In 2, Condition A or B, 24 hrs. min., +125°C min., Method 1015

100% Interim Electrical Test 2 (T2)

100% Delta Calculation (T0-T2)

100% PDA 1, Method 5004 (Notes 1and 2)

100% Dynamic Burn-In, Condition D, 240 hrs., +125°C or Equivalent, Method 1015

100% Interim Electrical Test 3 (T3)

100% Delta Calculation (T0-T3)

100% PDA 2, Method 5004 (Note 2)

100% Final Electrical Test

100% Fine/Gross Leak, Method 1014

100% Radiographic, Method 2012 (Note 3)

100% External Visual, Method 2009

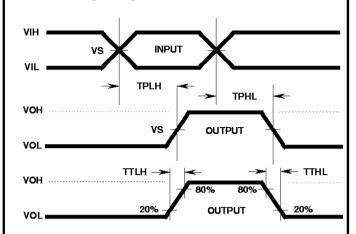
Sample - Group A, Method 5005 (Note 4)

100% Data Package Generation (Note 5)

NOTES:

- 1. Failures from Interim electrical test 1 and 2 are combined for determining PDA 1.
- 2. Failures from subgroup 1, 7, 9 and deltas are used for calculating PDA. The maximum allowable PDA = 5% with no more than 3% of the failures from subgroup 7.
- 3. Radiographic (X-Ray) inspection may be performed at any point after serialization as allowed by Method 5004.
- 4. Alternate Group A testing may be performed as allowed by MIL-STD-883, Method 5005.
- 5. Data Package Contents:
 - · Cover Sheet (Harris Name and/or Logo, P.O. Number, Customer Part Number, Lot Date Code, Harris Part Number, Lot Number, Quantity).
 - · Wafer Lot Acceptance Report (Method 5007). Includes reproductions of SEM photos with percent of step coverage.
 - GAMMA Radiation Report. Contains Cover page, disposition, Rad Dose, Lot Number, Test Package used, Specification Numbers, Test
 equipment, etc. Radiation Read and Record data on file at Harris.
 - · X-Ray report and film. Includes penetrometer measurements.
 - Screening, Electrical, and Group A attributes (Screening attributes begin after package seal).
 - · Lot Serial Number Sheet (Good units serial number and lot number).
 - · Variables Data (All Delta operations). Data is identified by serial number. Data header includes lot number and date of test.
 - The Certificate of Conformance is a part of the shipping invoice and is not part of the Data Book. The Certificate of Conformance is signed
 by an authorized Quality Representative.

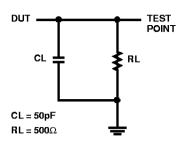
AC Timing Diagrams



AC VOLTAGE LEVELS

PARAMETER	HCS	UNITS
VCC	4.50	٧
VIH	4.50	٧
VS	2.25	٧
VIL	0	٧
GND	0	٧

AC Load Circuit



Die Characteristics

DIE DIMENSIONS:

87 x 88 mils 2.20mm x 2.24mm

METALLIZATION:

Type: AlSil

Metal Thickness: 11kÅ ± 1kÅ

GLASSIVATION:

Type: SiO_2 Thickness: $13k\mathring{A} \pm 2.6k\mathring{A}$

WORST CASE CURRENT DENSITY:

<2.0 x 10⁵A/cm²

BOND PAD SIZE:

100μm x 100μm 4 x 4 mils

Metallization Mask Layout

